

## Main Objectives of TF II in OP2.1 and OP2.2

Main Objective	Scientific Goal	Measures of Success / Deliverables
<ul> <li>Integrated scenarios for long- pulse operation with PFC heat load control, efficient particle exhaust, and impurity screening</li> </ul>	<ul> <li>Control of divertor/baffle loads and actuation of heat load distribution</li> <li>Studies on particle exhaust and optimization of plasma fueling schemes</li> </ul>	<ul> <li>Demonstration of safe divertor scenarios to avoid overloaded plasma-facing components</li> <li>Determination of trim and/or control coil currents required to correct error fields</li> <li>Demonstration of effective pumping, high divertor compression, and qualification of fueling actuators</li> <li>Demonstration of long-pulse operation (1 GJ energy turnaround)</li> </ul>
<ul> <li>Development of long, stationary divertor detachment scenarios with and without impurity seeding</li> </ul>	<ul> <li>Creating conditions for detachment by tailoring edge plasma conditions and impurity seeding</li> <li>Compatibility of stationary detachment with high- performance scenarios</li> <li>Development of detachment scenarios with efficient exhaust</li> </ul>	<ul> <li>Demonstration of scenarios with long, stationary divertor detachment; in particular, for the high-mirror, high-iota and standard configurations</li> <li>Characterize the conditions under which detachment is possible</li> <li>Achieve rapid transition to detachment</li> </ul>

<ul> <li>Exploration of scenarios compatible with carbon-free operation and tungsten PFCs</li> </ul>	<ul> <li>Migration (erosion, deposition) of tungsten-based materials and assessment of operation limits</li> <li>Edge scenario development for metallic plasma-</li> </ul>	<ul> <li>Definition of the operation limits associated with plasma- facing components containing tungsten materials</li> <li>Characterize the scrape-off layer retention for tungsten</li> </ul>
	facing components	<ul> <li>impurities (eroded from baffle and heat shield)</li> <li>Determination of erosion effects due to seeding impurities</li> <li>Characterize enrichment/accumulation for low-Z and high-Z impurities</li> </ul>
<ul> <li>Development of wall conditioning procedures</li> </ul>	<ul> <li>Optimization of glow discharge cleaning, boronization, and qualification of dedicated wall conditioning discharges with ECRH/ICRH</li> </ul>	<ul> <li>Condition walls to enable plasmas with high density gradients necessary for high performance</li> </ul>
Reference discharge	<ul> <li>Validation of edge models</li> <li>Tracking of plasma/wall conditions</li> <li>Analysis of configuration dependences (incl. reversed field operation)</li> </ul>	<ul> <li>Regular performance of a standardized discharge with defined diagnostic coverage throughout campaign</li> </ul>